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Docket No.: R2180.0193/P193
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Naohiro Ueda

Confirmation No.: 3147

Application No.: 10/801,838

Art Unit: N/A

Filed: March 17, 2004

Examiner: Not Yet Assigned

For: SEMICONDUCTOR APPARATUS AND
METHOD OF MANUFACTURING THE
SAME

FIRST PRELIMINARY AMENDMENT

MS Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

INTRODUCTORY COMMENTS

Prior to examination on the merits, please amend the above-identified U.S. patent application as follows:

Amendments to the Specification begin on page 3 of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on page 4 of this paper.

Amendments to the Drawings begin on page 9 of this paper and include both an attached replacement sheet and an annotated sheet showing changes.

Amendments to the Abstract begin on page 10 of this paper.

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Remarks/Arguments begin on page 11 of this paper.

A substitute specification, provided as clean and marked copies, and replacement abstract and drawing figures are attached following page 11 of this paper.